

Pd

PALLADIUM SPUTTERING TARGET

Palladium sputtering target shares properties with their source material. Palladium is a member of the platinum group of metals. physical vapor deposition (PVD) of thin films, laser ablation deposition (PLD), magnetron sputtering for semiconductor, display, LED and photovoltaic devices. Like platinum, its most prominent use in industry is as a catalytic converter. It can also found in jewelry and surgical instruments. Palladium is evaporated under vacuum for the manufacture of semiconductors, sensors, and data storage.

Quick Facts

Product	:	Palladium Sputtering Target
Stock No	:	NS6130-10-1044
CAS	:	7440-05-3
Backing Plate	:	(As per Customer requirement)

Additional Characteristics

Type of Bond	Purity	Diameter	Thickness
Indium, Elastomer	99.99%	50.8 mm ± 1mm	3 mm ± 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Thermal Conductivity
Pd	106.42 g/mol	72W/m.K



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 High Purity
 SPUTTERING
 TARGET

TARGET



20ZICE4589C



19ZAZGO1274G



20ZICE4588M

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